PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

n re the Application of

Attn: OIPE

Yasumasa FUJIOKA et al.

Group Art Unit: 3742

Application No.: 10/568,980

Docket No.: 127112

Filed: February 21, 2006

For:

PLASMA GENERATING ELECTRODE AND PLASMA REACTOR

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

Registration No. 27,075

Kristin K. Vidovich Registration No. 41,448

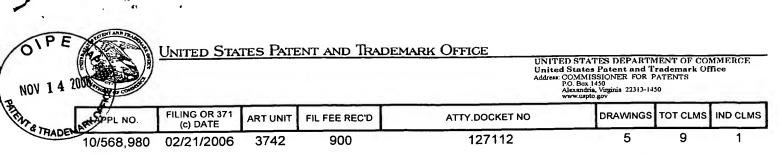
JAO:KKV/kam

Date: November 14, 2006

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CONFIRMATION NO. 8848

FILING RECEIPT

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Applicant(s)

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Assignment For Published Patent Application

NGK Insulator, Ltd., Nagoya-city, JAPAN Honda Motor Co., Ltd., Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/13211 09/10/2004

Foreign Applications

JAPAN 2003-322065 09/12/2003

If Required, Foreign Filing License Granted: 10/29/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US10/568,980

Projected Publication Date: 02/08/2007

Non-Publication Request: No

Early Publication Request: No

Title

Plasma generating electrode and plasma reactor

Preliminary Class

219

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